International Application No.: PCT/JP2004/012987

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REMARKS

Claims 5-19 are pending in this application. By this Preliminary Amendment, Applicants AMEND the specification and the abstract of the disclosure, CANCEL claims 1-4 and ADD new claims 5-19.

Applicants have attached hereto a Substitute Specification in order to make corrections of minor informalities contained in the originally filed specification. Applicants' undersigned representative hereby declares and states that the Substitute Specification filed concurrently herewith does not add any new matter whatsoever to the above-identified patent application. Accordingly, entry and consideration of the Substitute Specification are respectfully requested.

The changes to the specification have been made to correct minor informalities to facilitate examination of the present application.

Applicants respectfully submit that this application is in condition for allowance. Favorable consideration and prompt allowance are respectfully solicited.

Respectfully submitted,

Date: April 19, 2005

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DESCRIPTION

Attorney Docket No. 36856.1334

LAMINATED COIL COMPONENT AND METHOD OF MANUFACTURING THE SAME

TECHNICAL BACKGROUND OF THE INVENTION

1. Field of the Invention

The present invention relates to laminated coil components and methods of manufacturing the same. In particular, the present invention relates to conformationa unique arrangement of coil conductors inside ceramic laminates.

Background 2. Description of the Related Art

A longitudinally laminated and laterally coiled chip inductor disclosed in <u>Japanese Unexamined</u> Patent Document +Application

Publication No. 2002-252117 is an example of a laminated coil component. As shown in Fig. 11, a chip inductor 31 includes a coil conductor 33 having the an axis orthogonal that is perpendicular to the laminated direction (thickness direction) X inside an approximately rectangular parallelepiped ceramic laminate 32. Namely, the The coil conductor 33 having the axis extending in the longitudinal direction Y of the ceramic laminate 32 is provided inside the ceramic laminate 32. Strip electrodes 34 are disposed at the upper portion and the lower portion inside the ceramic

laminate 32. The ends of the strip electrodes 34 are connected with each other inside the ceramic laminate 32 through via-holes 35 passing through the ceramic laminate 32 in the thickness direction X to form the coil conductor 33.

The via-holes 35 are formed provided by providing forming through-holes at predetermined positions of locations in each ceramic green sheet constituting defining the ceramic laminate 32 and by filling these—the through-holes with a conductive material (conductive paste), such as an Ag paste. An example of the ceramic green sheet is a ferrite sheet. The two endmost strip electrodes 34 disposed at the upper portion of the ceramic laminate 32 extend to the side surfaces in the longitudinal direction Y of the ceramic laminate 32, and are connected to external electrodes 37 coated on the side surfaces of the ceramic laminate 32, respectively.

Regarding the preparation (not shown) of the ceramic laminate 32 of the chip inductor 31, a plurality of ceramic green sheets having only via-holes 35 only are stacked in the laminated direction X. Then, a plurality of ceramic green sheets having strip electrodes 34 and via-holes 35 are attacked attached on the top and the bottom of the resulting laminate of the ceramic green sheets. Furthermore, a plurality of ceramic green sheets without which do not have the strip electrodes 34 and the via-holes 35 are stacked on the top and the bottom of the resulting laminate of the ceramic green sheets.

The ceramic laminate 32 is prepared by press-bonding the laminated ceramic green sheets monolithically along the

laminated direction X, and by then firing. Then, the external electrodes 37 are formed on the side <u>surfaces</u> of the ceramic laminate 32 by dipping <u>with in</u> a conductive paste and subsequent firing. Thus, the chip inductor 31 having the dipped end surfaces is prepared.

Patent Document 1: Japanese Unexamined Patent Application
Publication No. 2002 252117

Disclosure of Invention

Problems to Be Solved by the Invention

The relative inductance (L) of a coil in a laminated coil component will now be investigated. For example, in the known chip inductor 31, the coil conductor 33 can havehas the highest relative inductance (L) when the inner crosssectional area (inner area) and the outer cross-sectional area (outer area) of the coil conductor 33 are the same as each other. Namely, the The highest relative inductance (L) can be is achieved when the laminated coil component is designed to have a ratio of approximately 1: 1 regarding these areas.

In the design of the chip inductor 31, some restrictions must be taken into account. The ceramic green sheets stacked for constitutingdefining outer coatings on the top position and the bottom position in the thickness direction X of the coil conductor 33 disposed inside the ceramic laminate 32 must have an outer-coating thickness largerthat is greater than a predetermined level-thickness in order to prevent Ag

diffusion. Side gaps in the width direction Z of the ceramic laminate 32 must be largergreater than a minimum gap required in order to prevent the exposure of the strip electrodes 34 and the via-holes 35 to the exterior regardless of distortion during laminating or cutting.

These restrictions are more noticeable as the outside dimension of the chip inductor 31 decreases. As a result, it is highly disadvantageous to design a coil conductor 33 having substantially equal inner area—and outer areas.

The ceramic laminate 32 of the chip inductor 31 is prepared by press-bonding laminated—a large number of ceramic green sheets, and by firing them after cutting. In general, the conductive material in the through-holes constituting defining the via-holes 35 are not readily deformed during the press-bonding as compared with—to the ceramic green sheets. Therefore, the conductive material functions as posts for resisting the compacting pressure during the press-bonding, and the via-holes 35 receive the compacting pressure.

Consequently, the compacting pressure applied to ceramic regions near the via-holes 35 which are densely aligned is smallerarranged is less than that applied to ceramic regions far away that are spaced from the via-holes 35. Because of low compacting pressure, delamination and insufficient sintering during firing readily occur at the ceramic regions near the via-holes 35. Furthermore, the conductive Ag material Ag-for the via-holes 35 is easily diffused, resultingwhich results in a decrease in insulating resistance

between the via-holes 35.

The present invention has been made to______
SUMMARY OF THE INVENTION

To overcome these disadvantages. It is an object the problems described above, preferred embodiments of the present invention to—achieve a high relative inductance (L) by equalizing the inner area and the outer area of a coil conductor, while the small—a reduced size and the—a thin shape are maintained. Furthermore, it is an object to preferred embodiments of the present invention provide a laminated coil component which can—effectively prevent prevents a decrease in insulating resistance between via-holes and also provide a method for manufacturing the same.

Summary of the Invention

A laminated coil component according to a first aspectpreferred embodiment of the present invention includes a coil conductor composed of including a plurality of strip electrodes and via-holes for connecting predetermined ends of the strip electrodes inside an approximately rectangular parallelepiped—ceramic laminate. The axis of the coil conductor corresponds with—to the width direction of the ceramic laminate—orthogonal, which is substantially perpendicular to both the laminated direction (thickness direction) and the longitudinal direction of the ceramic laminate. Namely, the—The—axis of the coil conductor is orthogonal substantially perpendicular to the laminated

direction (thickness direction) of the ceramic laminate and also orthogonal substantially perpendicular to the longitudinal direction of the ceramic laminate.

According to a second aspect of the present invention,

In the laminated coil component recited in the first aspect
is characterized that according to this preferred embodiment,
external electrodes are preferably disposed at end regions in
the longitudinal direction on a main surface in the laminated
direction of the ceramic laminate and are connected to the
ends of the coil conductor.

According to a third aspect of the present invention, the laminated coil component recited in the second aspect is characterized that the external electrodes The external electrodes preferably cover the regions where the via-holes are arranged.

A method according to a fourth aspect of the present invention—for manufacturing the laminated coil component described in the third aspectaccording to another preferred embodiment of the present invention includes the steps of laminating ceramic green sheets having the strip electrodes and/or the via-holes and ceramic green sheets having printed conductive patterns constituting defining the external electrodes, and press-bonding and firing the laminated ceramic green sheets.

Advantageous Effect of the Invention

In a laminated coil component having a built-in coil conductor, in order to achieve a reduction in size and

thickness, particularly, in order to achieve a low profile, the thickness of the laminated coil component is smallerless than its length and width. In such a conformation.construction, the inner area of the coil conductor is extremely-smaller-substantially-less than the outer area when the axis of the coil conductor corresponds with the longitudinal direction of a ceramic laminate.

The reduction in size and thickness of a laminated coil component according to preferred embodiments of the present invention is achieved by utilizing general characteristics of the laminated coil component. The laminated coil component according to preferred embodiments of the present invention can achieve achieves a high relative inductance (L) even if an outer-coating thickness and side gaps are minimized.

Accordingly, the bias characteristics are improved and a—the manufacturing cost is—costs are decreased because the number of the via-holes can be is reduced as compared with to that of a known component.

In the laminated coil component described in the first aspectpreferred embodiments described above, the axis of the coil conductor corresponds with the width direction of the ceramic laminate—orthogonal, which is substantially perpendicular to both the laminated direction (thickness direction) and longitudinal direction of the ceramic laminate. Therefore, the inner area of the coil conductor is prevented from being extremely smaller substantially less than the outer area, and the relative inductance (L) of the coil conductor can be is increased by the equality substantially equal sizes

of these areas. Accordingly, the bias characteristics are improved and a—the manufacturing cost is—costs are decreased because the number of the via-holes can be is reduced as compared with—to that of a known component.

In the laminated coil component described inaccording to the second aspectpreferred embodiments described above, the external electrodes are preferably disposed at end regions in the longitudinal direction on a main surface in the laminated direction of the ceramic laminate and are connected to the ends of the coil conductor. Namely In other words, in this laminated coil component, the external electrodes are preferably disposed on a main surface in the thickness direction, not on the side surfaces in the longitudinal direction of the ceramic laminate.

In general, the external electrodes of a known laminated coil component are formed by dipping the side <u>surfaces</u> of the ceramic laminate. The external electrodes <u>have are not</u> been disposed on a main surface of the ceramic laminate. In the laminated coil component according to <u>preferred embodiments</u> of the present invention, since the external electrodes are <u>preferably</u> disposed on a main surface of the ceramic laminate, a process for mounting the laminated coil component on a substrate or the like, i.e. a process for connecting the external electrodes of the laminated coil component to wiring patterns on a substrate, is <u>readilyeasily</u> performed.

For example, the external electrodes of the laminated coil component and the wiring patterns on the substrate can be readily easily connected to each other by wire-bonding or

with a bump disposed between each external electrode of the laminated coil component and each wiring pattern on the substrate. Preferably, the external electrodes are disposed at the inside of arranged so as to be spaced from the edge of a main surface of the ceramic laminate in order to avoid chipping or delamination during barreling. In such a structure, the stray capacitance is smallerless than that of the known product having dipped end surfaces.

In the laminated coil component described inaccording to the third aspectpreferred embodiments of the present invention described above, since the external electrodes are disposedarranged so as to cover the regions where the viaholes are arranged, the compacting pressure during the pressbonding of the ceramic laminate acts not only on the viaholes but also on the ceramic regions near the viaholes through the external electrodes. Therefore, the ceramic regions near the viaholes are also pressed with a compacting pressure that is substantially equal to that at the ceramic regions far spaced away from the viaholes.

Therefore, the occurrence of delamination and insufficient sintering during firing can be readily inhibited prevented at the ceramic regions near the viaholes. As a result, Ag diffusion to the ceramic region and a decrease in insulating resistance between the viaholes can be are effectively inhibited prevented.

When a mold is used for press-bonding, the surface of the external electrode disposed on a main surface of the ceramic laminate eanmay be formed flat. As a result, for

example, a bonding strength for binding a bonding wire to the external electrode is advantageously improved <u>as</u> compared with to that in the known external electrode formed by dipping.

In the process described in the fourth aspect of the present invention—for manufacturing the laminated coil component according to the preferred embodiments of the present invention described above, ceramic green sheets having the strip electrodes and/or the via-holes and ceramic green sheets having printed conductive patterns constituting defining the external electrodes are laminated, and then press-bonding and firing are performed. In such a process, the laminated coil component described in the third aspect—is readilyeasily manufactured.

In such a manufacturing process, after connecting the external electrodes to the coil conductor through the viaholes, the conductive patterns for the external electrodes can also be fired in a process for firing the ceramic laminate. Therefore, in order to form the external electrodes, the coating and firing processes for the conductive paste alone are unnecessary. Therefore, the processing eost—iscosts are reduced.

Best Mode for Carrying Out the Invention

An object to equalize the inner area and the outer area of a coil conductor to ensure a high relative inductance (L) of the coil conductor while satisfying a reduction in size and thickness of a laminated coil component and to

effectively prevent a decrease in insulating resistance between via holes is achieved by a significantly simple structure and process.

First embodiment

Fig. Other features, elements, steps,

characteristics and advantages of the present invention will

become more apparent from the following detailed description

of preferred embodiments thereof with reference to the

attached drawings.

BRIEF DESCRIPTION OF THE DRAWINGS

- Fig. 1 is a perspective view of a chip inductor of a laminated coil component according to a first preferred embodiment of the present invention.
- Fig. 2 is an exploded perspective view of the chip inductor.
- Fig. 3 is a graph showing relationships between inductance (L) characteristics and applied current.
- Fig. 4 is a graph showing rates of change of inductance
 (L) with applied current.
- Fig. 5 shows a relationship between a ratio of the areas of a coil conductor and bias characteristics.
- Fig. 6 is a side view of a first mounting structure of the chip inductor.
- Fig. 7 is a side view of a second mounting structure of the chip inductor.

- Fig. 8 is a side view of a third mounting structure of the chip inductor.
- Fig. 9 is a perspective view of an appearance of a chip inductor of a laminated coil component according to a second preferred embodiment of the present invention.
- Fig. 10 is an exploded perspective view of the chip inductor.
- Fig. 11 is a perspective view of an appearance of a chip inductor of a laminated coil component according to a first known example.

DETAILED DESCRIPTION OF PREFERRED EMBODIMENTS First Preferred Embodiment

Fig. 1 is a perspective view of a chip inductor of a laminated coil component according to a first preferred embodiment. Fig. 2 is an exploded perspective view of the chip inductor. Fig. 3 is a graph showing characteristics of relative inductance (L) with an applied current. Fig. 4 is a graph showing a rate of change in relative inductance (L) with an applied current. Fig. 5 shows a relationship between a ratio of the areas and bias characteristics in a coil conductor. Figs. 6 to 8 are side views of mounted chip inductors; Fig. 6 shows a first mounting structure, Fig. 7 shows a second mounting structure, and Fig. 8 shows a third mounting structure.

Referring to Figs. 1 showing the appearance and Fig. 2 showing the exploded structure, the chip inductor 1 preferably includes a coil conductor 4 composed of a

including a plurality of strip electrodes 2 and a large number of via-holes 3 inside an approximately rectangular parallelepiped—ceramic laminate 5. The via-holes 3 electrically and mechanically connect predetermined ends of the strip electrodes 2. In the chip inductor 1, the strip electrodes 2 are disposed at predetermined intervals at the upper portion and the lower portion in the laminated direction (thickness direction) X of the ceramic laminate 5, and the ends of the strip electrodes 2 are connected with the via-holes 3 passing through the ceramic laminate 5 in the thickness direction X sesuch that the coil conductor 4 is spiral-shaped.

In this structure, the axis of the coil conductor 4 corresponds with the width direction Z of the ceramic laminate 5 orthogonalthat is substantially perpendicular to both the laminated direction (thickness direction) X and the longitudinal direction Y of the ceramic laminate 5. Namely, the The direction of the axis of the coil conductor 4 is orthogonal substantially perpendicular to the laminated direction X of the ceramic laminate 5 and also orthogonal substantially perpendicular to the longitudinal direction of the ceramic laminate 5. One of the ends of each strip electrodes 2 aligned at the endmost positions in the width direction Z at the upper position of the ceramic laminate 5 is connected to the via-hole 3 passing through the ceramic laminate 5 in the thickness direction X and extending to the upper main surface in the thickness direction X of the ceramic laminate 5.

Exposed external electrodes 6 are disposed on end positions in the longitudinal direction Y of the upper main surface in the thickness direction X of the ceramic laminate 5. The via-holes 3 extend to the upper main surface of the ceramic laminate 5 and are electrically connected to the respective external electrodes 6. In the chip inductor 1, each of the external electrodes 6 is disposed on the top surface in the laminated direction X of the ceramic laminate 5 to cover the region where the via-holes 3 are aligned.

The strip electrodes 2 and the external electrodes 6 are formed on surfaces of ceramic green sheets 7

constitutingdefining the ceramic laminate 5 with a conductive material (conductive paste+), such as an Ag paste. In Fig. 2, three-layer strip electrodes 2 are formed; however, only preferably provided. However, one-layer strip electrodes 2 may be formed.provided. The via-holes 3 are formed, for example, by irradiating each of the ceramic green sheets 7 with a laser beam to provide through-holes at predetermined positions locations of the ceramic green sheets 7, and then by filling the through-holes with a conductive material, such as an Ag paste.

In the this preferred embodiment, the external electrodes 6 are each aligned at inner position than locations that are spaced from the edge of a main surface of the ceramic laminate 5. In this state, the external electrode 6 does electrodes 6 are not undergo-chippingchipped or delamination delaminated during a barreling process. However, the conformation present invention is not limited to such a

state.configuration. The external electrode 6 may extend to
the edge of the main surface of the ceramic laminate 5 (not
shown).

In the chip inductor 1, the axis of the coil conductor 4 corresponds with the width direction Z of the ceramic laminate 5 orthogonal that is substantially perpendicular to both the laminated direction (thickness direction) X and the longitudinal direction Y of the ceramic laminate 5. The fired chip inductor 1 preferably has a thickness of about 0.35 mm, a width of about 3.2 mm, an outer-coating thickness of about 0.04 mm, and side gaps of about 0.1 mm, for example. In such a chip inductor 1, the inner area and the outer area of the coil conductor 4 are very similar preferably substantially the same, i.e. it was observed by the inventors of the present invention that the ratio of these areas is approximately 1: 1.4 and the relative inductance (L) of the coil conductor 4 is approximately 1.1 µH, for example.

On the other hand, in a known chip inductor 31, for example, when the fired chip inductor has a thickness of about 0.35 mm, a width of about 1.6 mm, an outer-coating thickness of about 0.04 mm, and side gaps of about 0.1 mm, the ratio of the inner area and the outer area of the coil conductor 33 is approximately 1: 1.8. Therefore, the relative inductance (L) of the coil conductor 33 is only about 1.0 µH. It is also observed that the relative inductance (L) of the inventive chip inductor 1 is highergreater than that of the known chip inductor 31.

The results observed by the inventors on the measurement

of inductance (L) characteristics and the rate of change of inductance (L) at the application of as a current is applied are shown in Figs. 3 and 4. In Figs. 3 and 4, the solid lines represent the results in the inventive chip inductor 1 and the broken lines represent the results in the known chip inductor 31. As shown in Figs. 3 and 4, the inventive structure is superior to the known structure in both the inductance (L) characteristics and the rate of change of inductance (L).

Fig. 5 shows a relationship between the ratio of the areas and the bias characteristics of the coil conductor 4 at a current level when the inductance decreases by about_30%.

Namely, accordingAccording to the observed results, when the ratio of the inner area and the outer area of the coil conductor 4 is approximately 1: 1, the upper limit of an allowable current level is highergreater than that of a coil conductor having a ratio of the areas farthat is substantially different from 1: 1. Therefore, a high inductance is maintained even if a large amount of current is biased. As a result, in the chip inductor 1 having the structure according to the first preferred embodiment, the bias characteristics ean-be-are-improved while a high relative inductance (L) is maintained, even ifwhen the outer-coating thickness and side gaps are minimized.

Furthermore, in the chip inductor 1, the external electrodes 6 are disposed on a main surface of the ceramic laminate 5 and cover the regions where the via-holes 3 are disposed in the ceramic laminate 5. Therefore, during the

press-bonding of the ceramic laminate 5, a compacting pressure for the press-bonding acts not only on the via-holes 3 but also on ceramic regions near the via-holes 3 through the external electrodes. As a result, the ceramic regions amongin the vicinity of the via-holes 3 can be are sufficiently press-bonded and the occurrence of delamination and insufficient sintering during firing of the ceramic laminate 5 can be is prevented.

The inventors of the present invention investigated the relationship between a thickness of the external electrodes 6 disposed on a main surface of the ceramic laminate 5 and the rate of delamination. The rate of delamination was about 15% when the external electrodes 6 are not formed on the main surface of the ceramic laminate 5.

On the other hand, when the external electrodes 6 are formed by printing atto have a thickness of about 5 µm so as to have a thickness of about 3 µm after the press-bonding, the rate of delamination was about 10%. When the external electrodes 6 are formed by printing atto have a thickness of about 15 µm so as to have a thickness of about 10 µm after the press-bonding, the rate of delamination was 0%. It was observed that the rate of delamination is significantly improved by the presence of the external electrodes 6. In particular, it is preferable that the external electrodes 6 be printed atto have a thickness of at least about 15 µm—or more.

If delamination and insufficient sintering during firing of the ceramic laminate 5 can be is prevented, Ag diffusion

to the ceramic regions among the via-holes 3 and a decrease in insulating resistance between the via-holes are efficiently prevented. When the ceramic laminate 5 is press-bonded with a mold (not shown), external electrodes 6 having flat surfaces are formed. As a result, for example, the bonding strength between a bonding wire and the external electrode 6 is advantageously improved.

The inventors of the present invention compared the bonding strength of the external electrodes 6 plated with Ni (base) and Au on the main surface of the ceramic laminate 5 in the chip inductor 1 with the bonding strength of the external electrodes 37 plated with Ni (base) and Au on the side <u>surfaces</u> of the ceramic laminate 32 by dipping and firing in the known chip inductor 31. NamelyMore <u>specifically</u>, Au-wire bonding in these chip inductors was evaluated by a ball shear test and a wire pull test. The results of these tests showed that the chip inductor 1, i.e. the structure having the external electrodes 6 plated with Ni (base) and Au on the main surface of the ceramic laminate 5, has a bonding strength <u>higherthat is greater</u> than that of the etherknown chip inductor.

When the external electrodes 6 are disposed at regions near the edges in the longitudinal direction Y of the upper main surface in the thickness direction X of the ceramic laminate 5 in the chip inductor 1, various structures for mounting the chip inductor 1 can be employed used as described below. In a first mounting structure shown in Fig. 6, each of the external electrodes 6 of the chip inductor 1

and a wiring pattern 8 on a substrate on which the chip inductor 1 is mounted are readily easily bonded by wire bonding with an Au wire 9 or the like other suitable wire.

In a second mounting structure shown in Fig. 7, solder balls or Au balls 10 may be used for bonding. In this case, the solder balls or Au balls 10 are provided on the external electrodes 6 of the chip inductor 1, and are then bonded to the external electrodes 6 by reflowing or an ultrasonic treatment. Then, the chip inductor 1 is turned upside down and then—each of the solder balls or Au balls 10 is bonded to a wiring pattern 8 on a substrate by reflowing or the likeother suitable method.

In a third mounting structure shown in Fig. 8, each of the Au-plated external electrodes 6 of the chip inductor 1 and a wiring pattern 8 on a substrate may be directly connected, and then bonded by an ultrasonic treatment. Each of the external electrodes 6 of the chip inductor 1 and the wiring pattern 8 on the substrate on which the chip inductor 1 is mounted can be bonded with a conductive adhesive or anisotropic conductive tape (not shown). In such a mounting structure, since a high temperature by for soldering is not applied to the chip inductor 1, the chip inductor 1 does not undergo a change in the its characteristics.

A method for manufacturing the chip inductor 1 will now be described with reference to Fig. 2. A water-based binder (vinyl acetate, water-soluble acrylic resin, etc.) or an organic binder (polyvinyl butyral, etc.) is added to a magnetic material, i.e. Ni-Cu-Zn ferrite. After the addition

of a dispersant and antifoam, ceramic green sheets 7 are formed by doctor blading or with a reverse-roll coater. A predetermined number of the ceramic green sheets 7 are irradiated with a laser beam at predetermined positions of each ceramic green sheet 7 to form the through-holes for the via-holes 3.

The via-holes 3 are formed by filling the through-holes provided to formed in the ceramic green sheets 7 with an Ag paste by screen-printing. The strip electrodes 2 constituting parts defining portions of the coil conductor 4 are formed onat predetermined positions locations of the surface of each ceramic green sheet 7 by screen-printing an Ag paste. Conductive patterns constituting defining the external electrodes 6 are formed at predetermined positions locations on the surfaces of other ceramic green sheets 7.

A predetermined number of the ceramic green sheets 7 having only the via-holes 3 only are stacked in the laminated direction X. Then, a predetermined number of the ceramic green sheets 7 having the strip electrodes 2 and the via-holes 3 are stacked on the top and the bottom of the resulting laminate of the ceramic green sheets 7.

Furthermore, the ceramic green sheets 7 having the conductive patterns constitutingdefining the external electrodes 6 are stacked on the top of the resulting laminate of the ceramic green sheets 7 without any of the strip electrodes 2, the via-holes 3, and the conductive patterns constitutingdefining the external electrodes 6 are

also stacked on the bottom of the resulting laminate of the ceramic green sheets 7.

A sheet laminate 11 formed in such a process is press-bonded in the laminated direction X, and are—then cut into a predetermined size. Then, the ceramic laminate 5 is prepared by degreasing and firing. Subsequently, the external electrodes 6 are formed by Ni plating (base) and Au plating on the conductive patterns constituting defining the external electrodes 6 to complete the chip inductor 1. The plating may be performed with Ni (base) and Sn instead of Ni (base) and Au. The pressure during the press-bonding of the sheet laminate 11 ranges from about 98 MPa to about 120 MPa (from about 1.0 t/cm² to about 1.2 t/cm²).

In this manufacturing process, after the connecting the conductive patterns for the external electrodes 6 to the coil conductor 4 through the via-holes 3, the conductive patterns for the external electrodes 6 can be are fired in a process for firing the ceramic laminate 5. Therefore, in order to form the external electrodes 6, the coating and firing processes for the conductive paste alone are unnecessarynot required.

In a laminated coil component according to the <u>first</u> <u>preferred</u> embodiment, the chip inductor 1 is <u>preferably</u> provided with one coil conductor 4 inside the ceramic laminate 5. However, the laminated coil component according to the present invention is not limited to the abovementioned chip inductor 1. <u>NamelyParticularly</u>, a plurality of coil conductors 4 may be aligned in parallel inside the

ceramic laminate 5. The chip inductor having such a structure is <u>preferably</u> used as a transformer or a common mode choke coil. Furthermore, the present invention can be applied to other laminated coil components, such as a multilayer <u>impedorcapacitor</u>, inductor, and a multilayer LC filter.

Second embodimentPreferred Embodiment

Fig. 9 is a perspective view of an appearance of a chip inductor according to a second <u>preferred</u> embodiment of the present invention. Fig. 10 is an exploded perspective view of the chip inductor. The chip inductor is represented by reference numeral 21. The structure of the chip inductor 21 according to this <u>preferred</u> embodiment is <u>preferably</u> substantially the same as that of the chip inductor 1 according to the first <u>preferred</u> embodiment except for the structure of the external electrodes.

Therefore, in Figs. 9 and 10, the same elements which are the same as those indescribed with reference to Figs. 1 and 2 are referred to with the same reference numerals as in Figs, 1 and 2, and the detailed description of these parts are elements is omitted. Since the manufacturing process and the function of the chip inductor 21 according to the second preferred embodiment are also substantially the same as those of the chip inductor 1 according to the first preferred embodiment, the detailed description thereof is omitted here.

The chip inductor 21 has a similar an appearance and exploded structure to that are similar those of the chip

specifically, the chip inductor 21 includes a coil conductor 4 composed of including a plurality of strip electrodes 2 and a large number of via-holes 3 inside an approximately rectangular parallelepiped ceramic laminate 22. The via-holes 3 electrically and mechanically connect predetermined ends of the strip electrodes 2. The axis of the coil conductor 4 corresponds with the width direction Z of the ceramic laminate 22 orthogonal that is substantially perpendicular to both the laminated direction (thickness direction) X of the ceramic laminate 22 and the longitudinal direction Y of the ceramic laminate 22.

One of the ends of each strip electrodes 2 aligned at the endmost positions outermost locations in the width direction Z at the upper position of the ceramic laminate 22 is connected to the via-hole 3 passing through the ceramic laminate 22 in the thickness direction X and extending to the upper main surface in the thickness direction X of the ceramic laminate 22. External electrodes 23 are disposed at the side positions portions in the longitudinal direction Y of the upper main surface in the thickness direction X of the ceramic laminate 22.

Each of the external electrodes 23 includes a pair of top electrodes 24 that are spaced apart from each other and a bottom electrode 25 disposed directly below the top electrodes 24. The top electrodes 24 and the bottom electrode 25 are connected through the via-holes 3. The external electrodes 23 are disposed on the top surface in the

laminated direction X of the ceramic laminate 22 to cover the regions where the via-holes 3 are aligned.

A method for manufacturing the chip inductor 21 will now be described with reference to Fig. 10. Ceramic green sheets 7 are formed first. Then, through-holes for the via-holes 3 are formed at predetermined positions of a predetermined number of the ceramic green sheets 7. Subsequently, the through-holes are filled with an Ag paste by screen-printing to form via-holes 3. Strip electrodes 2 constituting partsdefining portions of a coil conductor 4 are formed at predetermined positionslocations on each surface of the ceramic green sheets 7 by screen-printing an Ag paste.

Conductive patterns constitutingdefining the top electrodes 24 and the bottom electrodes 25 of the external electrodes 23 are formed at predetermined positions locations on the surfaces of other ceramic green sheets 7. A predetermined number of the ceramic green sheets 7 having only the via-holes 3 only—are stacked in the laminated direction X. Then, a predetermined number of the ceramic green sheets 7 having both the strip electrodes 2 and the via-holes 3 are stacked on the top and the bottom of the resulting laminate of the—ceramic green sheets 7.

Furthermore, the ceramic green sheet 7 having the conductive patterns constituting defining the bottom electrodes 25 of the external electrodes 23 is stacked on the top of the resulting laminate of the ceramic green sheets 7. Then, the ceramic green sheet 7 having the conductive patterns constituting defining the top electrodes 24 of the

external electrodes 23 is stacked on the top of the resulting laminate of the ceramic green sheets 7. On the other hand, on the bottom of the resulting laminate of the ceramic green sheets 7, the ceramic green sheets 7 without any of the strip electrodes 2, the via-holes 3, and the conductive patterns for the top electrodes 24 and the bottom electrodes 25 of the external electrodes 6 are stacked.

A sheet laminate 27 formed in such a process is pressbonded along the laminated direction X, and is then cut
intoto have a predetermined size. Then, the ceramic laminate
22 is prepared by degreasing and firing. Subsequently, the
external electrodes 23 are formed by plating the conductive
patterns constituting defining the top electrode 24 of the
external electrodes 23 with Ni (base) and Au to complete the
chip inductor 21 having an appearance shown in Fig. 9. Since
the Au-plated region of the chip inductor 21 having such a
structure is narrower than that of the chip inductor 1
according to the first preferred embodiment, a-manufacturing
cost can be costs are reduced.

Industrial Applicability

The laminated coil component is not limited to <u>a</u> chip inductor. A laminated coil component having two or more coil conductors arranged in parallel inside a ceramic laminate may be used in a transformer and a common-mode choke coil. Furthermore, the present invention can be applied to other laminated coil components such as multilayer <u>impedorscapacitors</u>, inductors, and multilayer LC filters.

Brief Description of the Drawings Fig. 1 is a perspective view of an appearance of a chip inductor of a laminated coil component according to a first embodiment-of the present-invention. Fig. 2-is an exploded perspective view of the chip inductor. - Fig. 3 is a graph showing relationships between inductance (L) characteristics and applied current. - Fig. 4 is a graph showing rates of change of inductance (L) with applied current. - Fig. 5 shows a relationship between a ratio of the areas of a coil conductor and bias characteristics. -- Fig. 6 is a side view of a first mounting structure of the chip inductor. - Fig. 7 is a side view of a second mounting structure of the chip inductor. Fig. 8 is a side view of a third mounting structure of the chip inductor. Fig. 9 is a perspective view of an appearance of a chip inductor of a laminated coil component according to a second embodiment of the present invention. Fig. 10 is an exploded perspective view of the chip inductor. - Fig. 11 is a perspective view of an appearance of a chip inductor of a laminated coil component according to a known example.

Reference Numerals
- 1 chip inductor (laminated coil component)
- 2 strip electrode
3 via hole
While the present invention has been described
with respect to preferred embodiments, it will be apparent to
those skilled in the art that the disclosed invention may be
modified in numerous ways and may assume many embodiments
other than those specifically set out and described above.
Accordingly, it is intended by the appended claims to cover
all modifications of the present invention that fall within
the true spirit and scope of the invention.